

comments to clarify that the invention in accordance with the disclosure includes filling the gaps using high density plasma chemical vapor disposition.


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Claims 5-8 depend on claim 1, claims 10-19 depend on claim 9, ~~and claim 3 is cancelled~~. Accordingly, these remaining claims are deemed also to be allowable for the same reasons set forth above with respect to independent claims 1 and 9. Reconsideration and withdrawal of the rejection is respectfully requested.

Claim 2 stands rejected under 35 U.S.C. § 112, second paragraph, as being indefinite. Applicants have amended claim 2 in accordance with the Examiner's comments. The rejection is therefore deemed to be inapplicable to the amended claims. Therefore, reconsideration and withdrawal of the rejection is respectfully requested.

In view of the above, all of the claims are believed to be in condition for allowance, and such a Notice, with allowed claims 1, 2 and 4-21, is earnestly solicited.

Respectfully submitted,

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AMENDMENT

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